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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/047,610	01/16/2002	Carl P. Babcock	039153-0325	5742	
7:	590 04/09/2004		EXAM	INER	
Steven C. Bec	ker		ROSASCO, STEPHEN D		
Foley & Lardne 777 East Wisco	er, Firstar Center onsin Avenue		ART UNIT PAPER NUMBER		
Milwaukee, W	I 53202-5367		1756		
			DATE MAILED: 04/09/2004	4	

Please find below and/or attached an Office communication concerning this application or proceeding.

<u> </u>	<u></u>		imp-
· Š	Application No.	Applicant(s)	
Advisory Action	10/047,610	BABCOCK ET AL.	
	Examiner	Art Unit	
	Stephen Rosasco	1756	
The MAILING DATE of this communication app	pears on the cover sheet with the	correspondence addre	9SS
THE REPLY FILED 19 March 2004 FAILS TO PLACE Therefore, further action by the applicant is required to final rejection under 37 CFR 1.113 may only be either: condition for allowance; (2) a timely filed Notice of App Examination (RCE) in compliance with 37 CFR 1.114.	avoid abandonment of this appl (1) a timely filed amendment wi	lication. A proper repl	y to a ation in
<u> </u>	EPLY [check either a) or b)]		
a) The period for reply expires 3 months from the mailing date b) The period for reply expires on: (1) the mailing date of this Ar event, however, will the statutory period for reply expire later ONLY CHECK THIS BOX WHEN THE FIRST REPLY WA 706.07(f).  Extensions of time may be obtained under 37 CFR 1.136(a). The o	dvisory Action, or (2) the date set forth in than SIX MONTHS from the mailing date S FILED WITHIN TWO MONTHS OF TI	of the final rejection. HE FINAL REJECTION. Se	e MPEP
have been filed is the date for purposes of determining the period of extended at the filed is the date for purposes of determining the period of extended at the filed at the shortened by the office later than three nearned patent term adjustment. See 37 CFR 1.704(b).	ension and the corresponding amount of the ed statutory period for reply originally set i	ne fee. The appropriate extended in the final Office action; or (2)	nsion fee under 2) as set forth in
1 A Notice of Appeal was filed on Appellan 37 CFR 1.192(a), or any extension thereof (37 C			
$2. \square$ The proposed amendment(s) will not be entered	because:		
(a)  they raise new issues that would require furt	her consideration and/or search	(see NOTE below);	
(b)  they raise the issue of new matter (see Note	e below);		
(c) they are not deemed to place the application issues for appeal; and/or	n in better form for appeal by ma	aterially reducing or si	mplifying the
(d)  they present additional claims without cance NOTE:	eling a corresponding number o	f finally rejected claim	S.
3.⊠ Applicant's reply has overcome the following rejection.	ection(s): none		
Newly proposed or amended claim(s) would canceling the non-allowable claim(s).		separate, timely filed	amendment
5. ☐ The a) ☐ affidavit, b) ☐ exhibit, or c) ☐ request to application in condition for allowance because: _	for reconsideration has been co	nsidered but does NO	T place the
6. The affidavit or exhibit will NOT be considered by raised by the Examiner in the final rejection.		Y to issues which were	e newly
7. For purposes of Appeal, the proposed amendme explanation of how the new or amended claims			ind an
The status of the claim(s) is (or will be) as follows	s:		
Claim(s) allowed:			
Claim(s) objected to:			
Claim(s) rejected:			
Claim(s) withdrawn from consideration:			
8. The drawing correction filed on is a) ap	oproved or b) disapproved b	y the Examiner.	•
9. Note the attached Information Disclosure Statem			
10. \( \times \) Other: See Continuation Sheet	, , , , , , , , , , , , , , , , , , , ,		
			. *

Continuation of 10. Other: the cited prior art to Tanaka et al. teach etching the substrate to two different depths for phase shifting. In the claimed invention the same mask is to be used with two different exposure wavelengths, but the mask is still the same.

S. ROSASCO RIMARY EXAMINER GROUP 1500

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